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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/795,801	03/09/2004	Henricus Wilhelmus Maria Van Buel	1857.2720000	7706
26111	7590 10/06/2005		EXAMINER	
STERNE, KESSLER, GOLDSTEIN & FOX PLLC 1100 NEW YORK AVENUE, N.W.			CHACKO DAVIS, DABORAH	
	WASHINGTON, DC 20005		ART UNIT	PAPER NUMBER
	•		1756	• • • • • • • • • • • • • • • • • • • •

DATE MAILED: 10/06/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

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	Application No.	Applicant(s)				
Office Action Summary	10/795,801	VAN BUEL, HENRICUS WILHELMUS MARIA				
,	Examiner	Art Unit				
The MAN INO DATE - SAL's	Daborah Chacko-Davis	1756				
The MAILING DATE of this communication Period for Reply	on appears on the cover sheet with	n the correspondence address				
A SHORTENED STATUTORY PERIOD FOR F WHICHEVER IS LONGER, FROM THE MAILII - Extensions of time may be available under the provisions of 37 of after SIX (6) MONTHS from the mailing date of this communicat - If NO period for reply is specified above, the maximum statutory - Failure to reply within the set or extended period for reply will, by Any reply received by the Office later than three months after the earned patent term adjustment. See 37 CFR 1.704(b).	NG DATE OF THIS COMMUNIC, CFR 1.136(a). In no event, however, may a rep- tion. period will apply and will expire SIX (6) MONTH y statute, cause the application to become ABAI	ATION. lly be timely filed HS from the mailing date of this communication. NDONED (35 U.S.C. § 133).				
Status						
1) Responsive to communication(s) filed on <u>09 March 2004</u> .						
2a)☐ This action is FINAL . 2b)⊠	This action is FINAL . 2b)⊠ This action is non-final.					
3)☐ Since this application is in condition for a	☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is					
closed in accordance with the practice ur	closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.					
Disposition of Claims		•				
4)⊠ Claim(s) <u>1-11</u> is/are pending in the application.						
4a) Of the above claim(s) is/are wi	4a) Of the above claim(s) is/are withdrawn from consideration.					
5) Claim(s) is/are allowed.						
6)⊠ Claim(s) <u>1-11</u> is/are rejected.	•					
7) Claim(s) is/are objected to.						
8) Claim(s) are subject to restriction and/or election requirement.						
Application Papers						
9)☐ The specification is objected to by the Examiner.						
10)☐ The drawing(s) filed on is/are: a)☐ accepted or b)☐ objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).						
11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.						
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of:						
1. Certified copies of the priority documents have been received.						
 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage 						
application from the International Bureau (PCT Rule 17.2(a)).						
* See the attached detailed Office action for a list of the certified copies not received.						
	·					
Attachment(s)						
1) Notice of References Cited (PTO-892) 4) Interview Summary (PTO-413)						
Paper No(s)/Mail Date Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Notice of Informal Patent Application (PTO-152)						
Paper No(s)/Mail Date <u>2/05, 2/10/05, 7/05</u> . 6) Other:						

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DETAILED ACTION

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.
- 2. Claims 1-11, are rejected under 35 U.S.C. 102(e) as being anticipated by U. S. Patent Application Publication No. 2003/0030781 (Bleeker et al).

Bleeker, in [[0008], [0009], [0032], [0035], [0036], [0037], [0038], [0039], [0040], [0041], discloses a lithographic apparatus comprising an illumination source (single source), an illumination system that produces a plurality of sub-beams, a patterning structure that includes a plurality of patterning sub-elements (spaced apart, individually controllable elements, see figure 3), a substrate table configured to hold a substrate, a projection system that projects the patterned sub-beams into a single patterned image on target portion of a layer of radiation-sensitive material that at least partially covers the substrate (claims 1, 4, 10-11). Bleeker, in [0045], discloses that the projection system includes a plurality of field lens system (see I1 to I6 of figure 4) that corresponds to the number of the patterning sub-elements, wherein the pattering sub elements create images I1 to I6 at the object plane of the PL (claim 2). Bleeker, in [0053]; discloses the magnification of the projection system as recited in claim 3. Bleeker, in

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[[0051], [0058], discloses that the illumination system includes attenuators that attenuate the patterned sub-beams of radiation (claim 5). Bleeker, in [0053], [0054], discloses that the projection beam is projected via bema splitters and are further sub-divided and directed to the corresponding patterning arrays (first through fourth patterning arrays) (see figures 8, 9, and 10) (claims 6-9).

Conclusion

3. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Daborah Chacko-Davis whose telephone number is (571) 272-1380. The examiner can normally be reached on M-F 9:30 - 6:00. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Mark F Huff can be reached on (571) 272-1385. The fax phone number for the organization where this application or proceeding is assigned is (571) 273-8300. Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

dcd

October 3, 2005.

JOHN A. MCPHERSON PRIMARY EXAMINER